

L13 ANSWER 1 OF 2 WPIX COPYRIGHT 2006 THE THOMSON CORP on STN
 AN 1986-025245 [04] WPIX
 DNN N1986-018379 DNC C1986-010680
 TI Forming fine contoured pattern on moulding - involves applying
 photosensitive resin between base film surface and mould surface.
 DC A32 G06 P75 P83 S06 T04
 PA (NIPQ) DAINIPPON PRINTING CO LTD
 CYC 1
 PI JP 60247590 A 19851207 (198604)* 3 <--
 ADT JP 60247590 A JP 1984-103992 19840523
 PRAI JP 1984-103992 19840523
 IC B41J005-12; B41M003-06; C08J007-04; G03C005-00
 AB JP 60247590 A UPAB: 19930922
 A method of forming a fine contoured pattern includes treating the surface
 of a mould having on the surface a fine contoured pattern and also smooth
 surface part with a releasing treatment, applying a photosensitive resin
 on the surface, placing a base film on there, exposing them to light so
 that the resin is hardened, and removing the mould.
 1,2/2
 FS CPI EPI GMPI
 FA AB
 MC CPI: A08-M03; A11-B04B; A11-C02B; A12-B07; G06-D; G06-F03
 EPI: S06-A01X; T04-G04

L13 ANSWER 2 OF 2 JAPIO (C) 2006 JPO on STN
 AN 1985-247590 JAPIO
 TI FORMATION OF PICTURE PATTERN HAVING FINE EMBOSSED PATTERN
 IN NAGASAKI OSAMU
 PA DAINIPPON PRINTING CO LTD
 PI JP 60247590 A 19851207 Showa
 AI JP 1984-103992 (JP59103992 Showa) 19840523
 PRAI JP 1984-103992 19840523
 SO PATENT ABSTRACTS OF JAPAN (CD-ROM), Unexamined Applications, Vol. 1985
 IC ICM B41M003-06
 ICS B41J005-12; C08J007-04; G03C005-00
 AB PURPOSE: To inexpensively prepare a facing paper, by a method wherein the
 fine embossed pattern and smooth surface of a matrix are transferred on a
 cured resin and a character, a mark or a color is printed to a base film
 from the back surface thereof in matching relation to the transferred
 pattern by screen printing.
 CONSTITUTION: Releasing treatment is applied to the surface of a matrix 1
 having fine embossed patterns 11A and partial smooth surfaces 12A on the
 surface thereof and a photosensitive resin 2A is applied to the treated
 surface of said matrix 1 while a base film 3 is laminated to the resin
 which is, in turn, exposed through said film 3 to be cured before the
 matrix 1 is released. After the fine embossed patterns 11A and the smooth
 surfaces 12A of the matrix 1 are transferred to the cured resin 2B as
 mentioned above, a character, a mark or a color is printed on said base
 film 3 from the back surface thereof in matching relation to the
 transferred patterns by screen printing. By this method, a facing paper
 provided with a picture pattern, which has the fine embossed patterns and
 the smooth surfaces corresponding to the matrix in combination, and having
 printing 4 on the back surface thereof can be formed.
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